

SEMICONDUCTOR DEVICES

Carrier Transport: Part 2



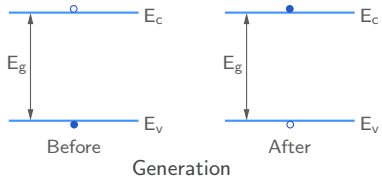
M. B. Patil

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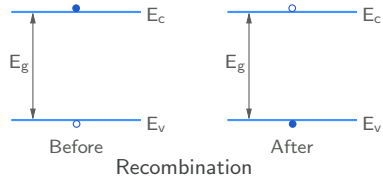
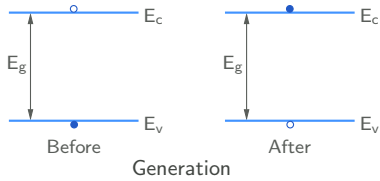
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Department of Electrical Engineering
Indian Institute of Technology Bombay

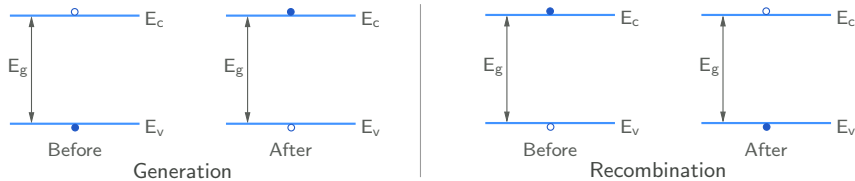
Generation and recombination



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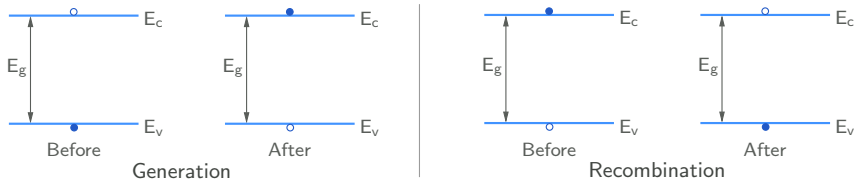


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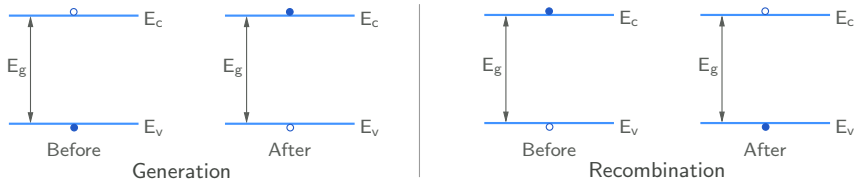
- * The processes of generation and recombination of electron-hole pairs (EHPs) take place continuously.

Generation and recombination



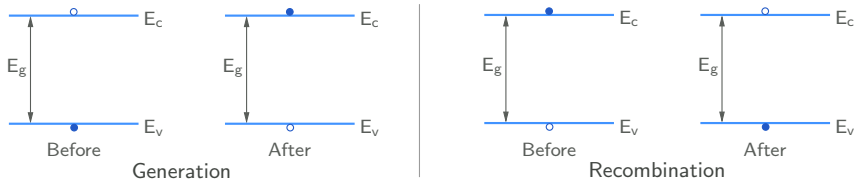
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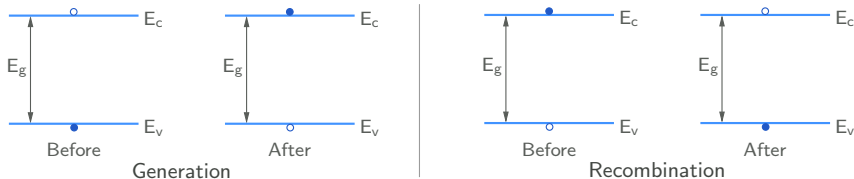
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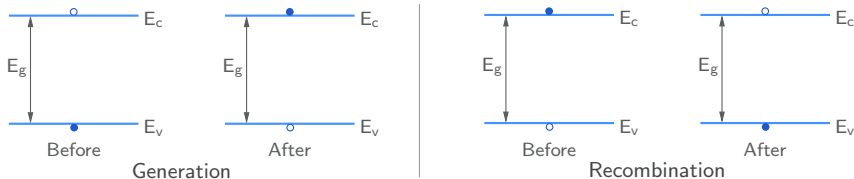
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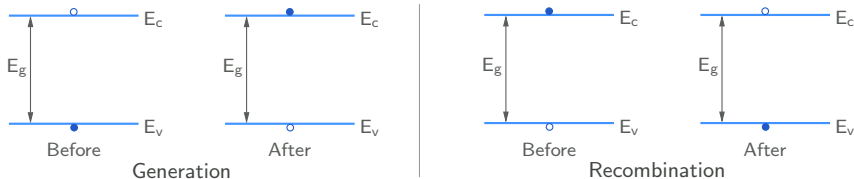
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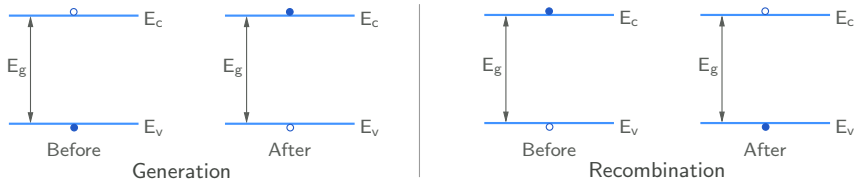
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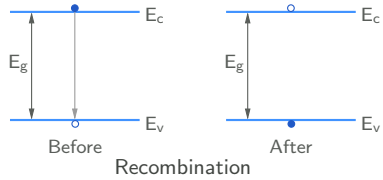
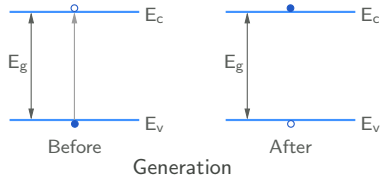
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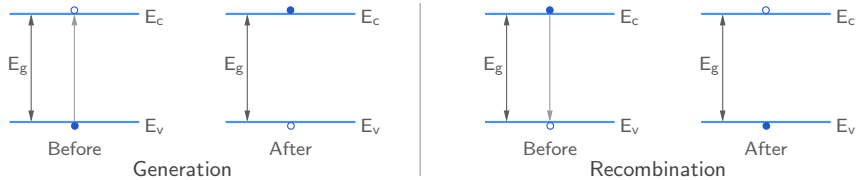


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- * The rates of generation and recombination depend on several factors:
 - band structure of the semiconductor
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 - temperature
- * Some of these processes, with very small rates, may be completely ineffective, while others may be dominant.

Direct G-R

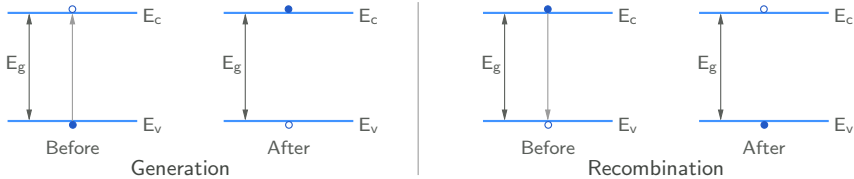


* Direct recombination



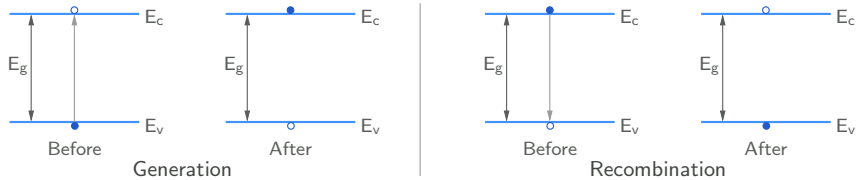
* Direct recombination

- An electron from the conduction band combines directly with a hole in the valence band, thus destroying an EHP.



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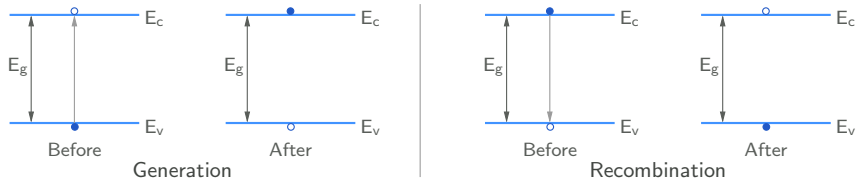
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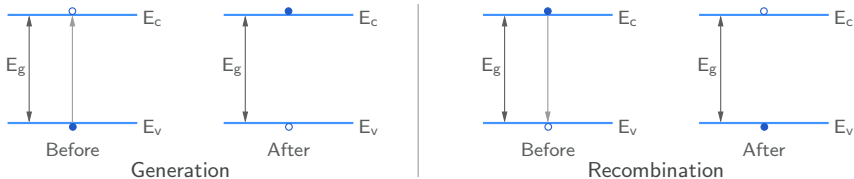


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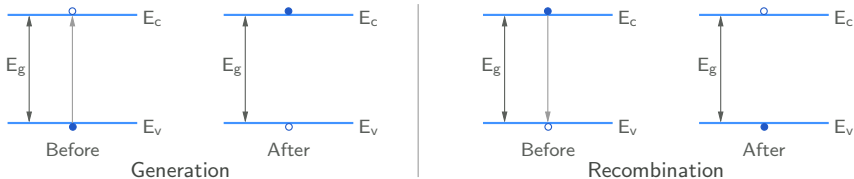


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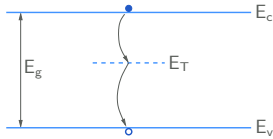
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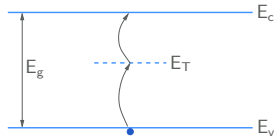
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- * Since particles from both conduction and valence bands are simultaneously involved, the above processes are called “band-to-band” G-R.



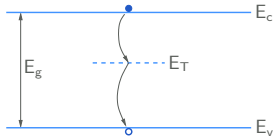
Recombination



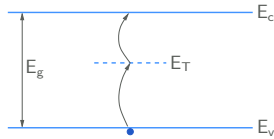
Generation

- * In indirect G-R, the transitions from the conduction band to the valence band (and *vice versa*) take place through a “G-R centre,” with an energy level E_T located in the forbidden gap.

Indirect G-R

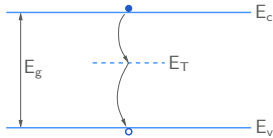


Recombination

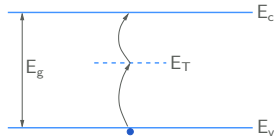


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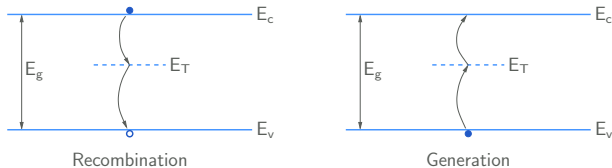


Recombination

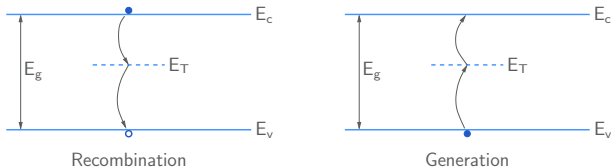


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- * Recombination or generation takes place in two steps.

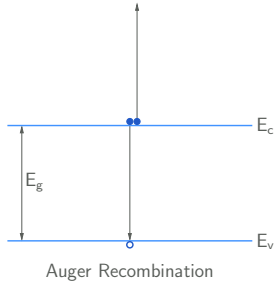


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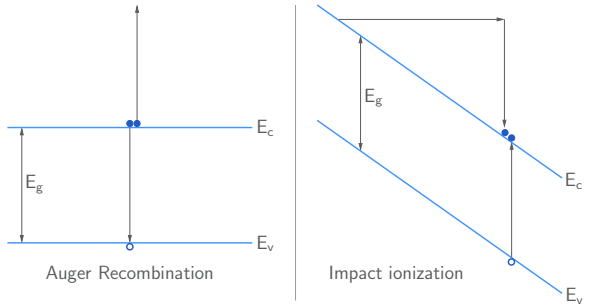


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- * Indirect G-R processes are particularly efficient when E_T lies close to the middle of the band gap.

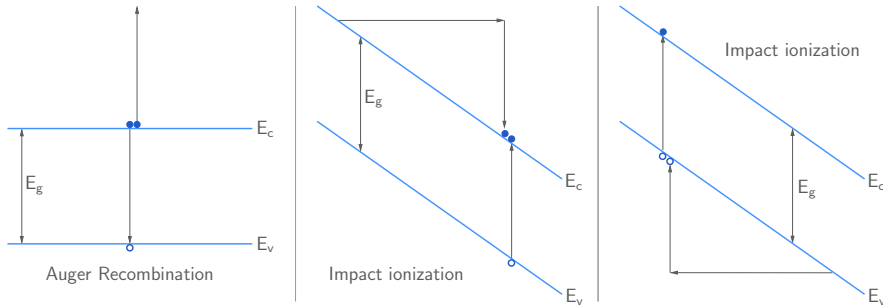
G-R with three particles



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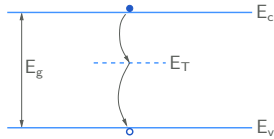


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- * In the reverse process of impact ionisation, a high-energy electron loses its energy ($> E_g$) but remains in the conduction band, and the energy is used by a valence band electron to make a transition to the conduction band, thus generating an EHP.

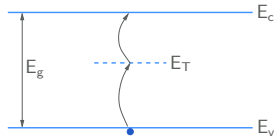


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Non-radiative G-R in silicon



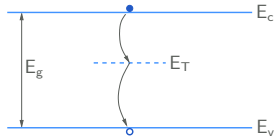
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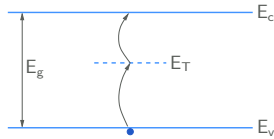
Generation

- * In silicon, the dominant non-radiative G-R process is that involving a G-R centre.

Non-radiative G-R in silicon



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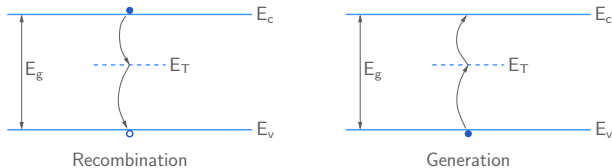


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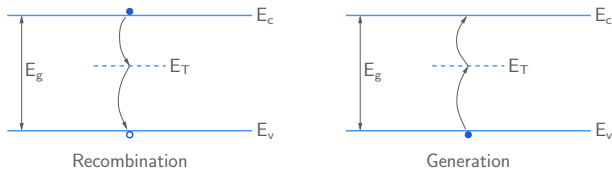
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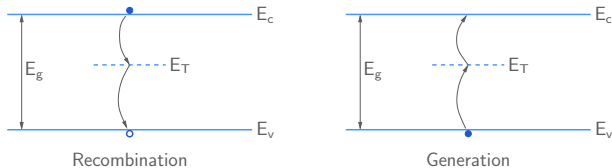
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$$n_1 = n_i e^{(E_T - E_i)/kT}, \quad p_1 = n_i e^{(E_i - E_T)/kT}.$$

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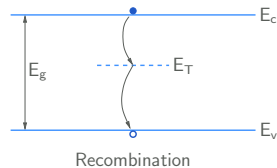
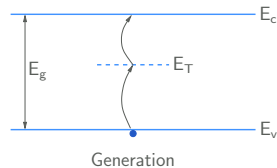


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- * Since the most effective G-R centres have $E_T \approx E_i$, n_1 and p_1 are generally much smaller than the majority carrier density in a doped semiconductor.

SRH formula: special case

$$R - G = \frac{np - n_i^2}{\tau_p(n + n_1) + \tau_n(p + p_1)}.$$

Let us consider a semiconductor in which electrons are the majority carriers, with the equilibrium values of n and p given by $n_0 = 10^{16} \text{ cm}^{-3}$, $p_0 = 10^4 \text{ cm}^{-3}$.

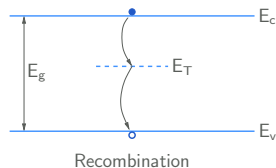
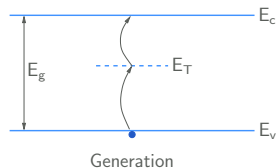


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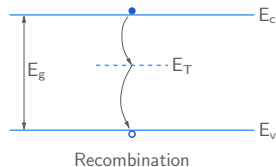
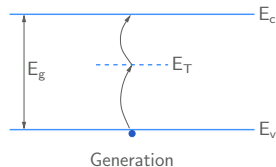
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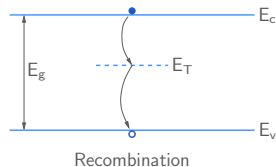
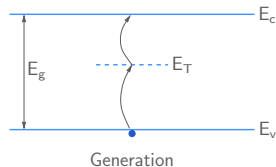
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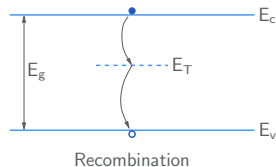
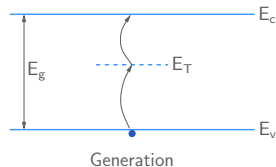
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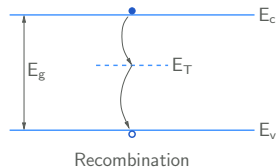
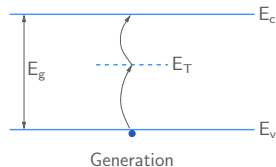
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SRH formula: special case

$$R - G = \frac{np - n_i^2}{\tau_p(n + n_1) + \tau_n(p + p_1)}.$$

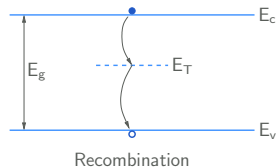
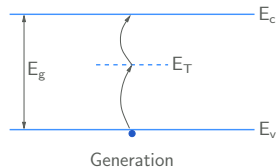
Let us consider a semiconductor in which electrons are the majority carriers, with the equilibrium values of n and p given by $n_0 = 10^{16} \text{ cm}^{-3}$, $p_0 = 10^4 \text{ cm}^{-3}$.

Suppose that additional carriers are created in the semiconductor (e.g., by shining light on the sample), giving rise to “excess concentrations” $\Delta p = \Delta n = 10^{12} \text{ cm}^{-3}$.

The total concentrations are $n = n_0 + \Delta n$ and $p = p_0 + \Delta p$,

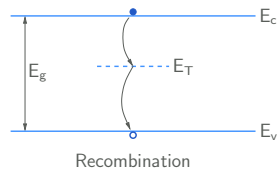
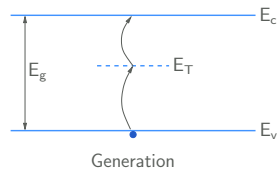
Applying the SRH formula, we get

$$\begin{aligned} R - G &= \frac{(n_0 + \Delta n)(p_0 + \Delta p) - n_i^2}{\tau_p(n + n_1) + \tau_n(p + p_1)} \\ &= \frac{p_0 \Delta n + n_0 \Delta p + \Delta n \Delta p}{\tau_p(n + n_1) + \tau_n(p + p_1)} \quad \because n_0 p_0 = n_i^2 \\ &\approx \frac{p_0 \Delta n + n_0 \Delta p}{\tau_p(n_0 + \Delta n)} \quad \because n_1 \ll n_0, \quad p + p_1 \ll n_0 \\ &\approx \frac{n_0 \Delta p}{\tau_p n_0} = \frac{\Delta p}{\tau_p}. \end{aligned}$$



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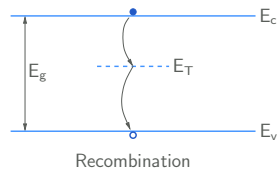
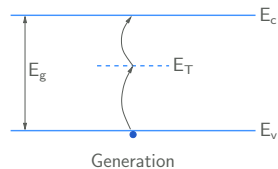
$$\approx \frac{\Delta p}{\tau_p} \quad (p_0 \ll n_0, \Delta n = \Delta p \ll n_0)$$



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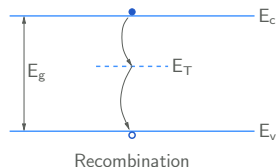
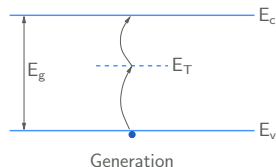
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In conclusion,

- * If the excess carrier densities Δn and Δp are small compared to the majority carrier density, the net recombination rate is governed by the minority carrier lifetime.



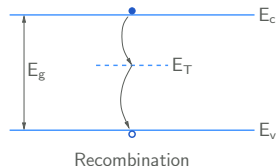
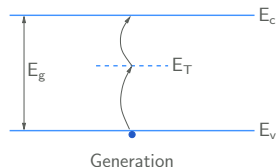
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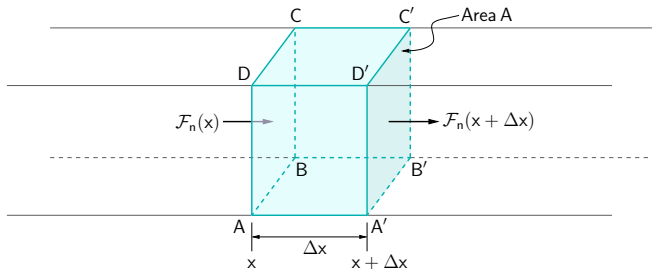
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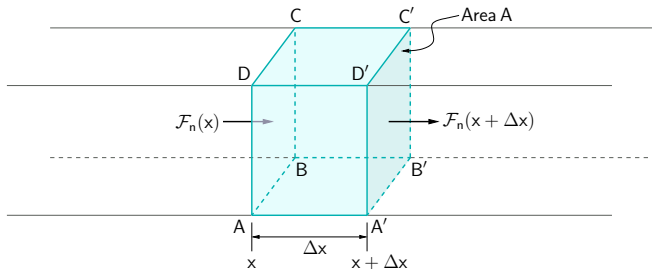
In conclusion,

- * If the excess carrier densities Δn and Δp are small compared to the majority carrier density, the net recombination rate is governed by the minority carrier lifetime.
- * We will find this result useful in our discussion of diodes and bipolar junction transistors.



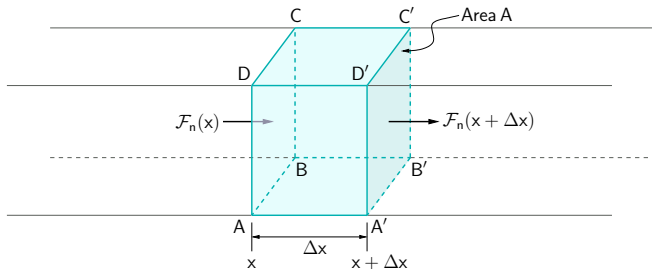


Two processes can change the number of electrons and holes in the box:



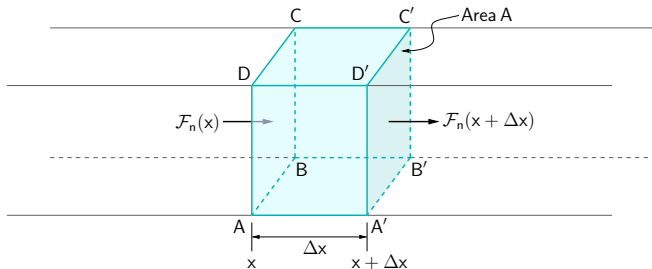
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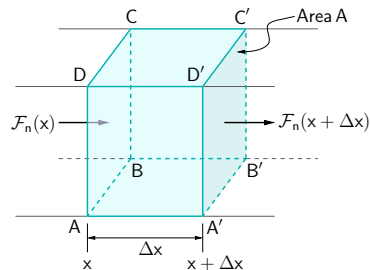
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The continuity equations serve to relate these phenomena.

Continuity equations

Assume that there are no variations of n , p , ψ in the y and z directions.

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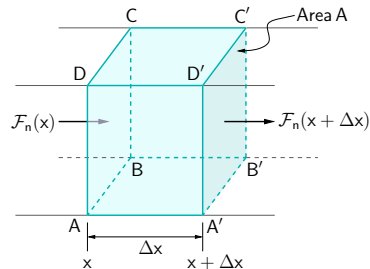
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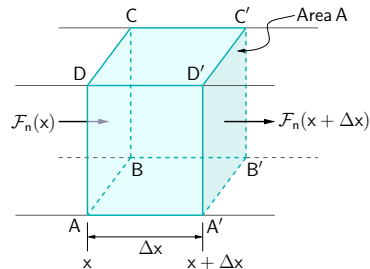
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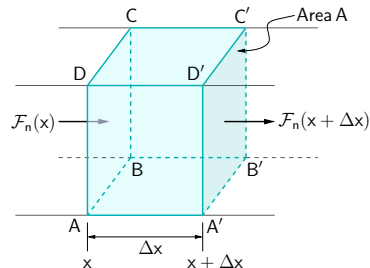
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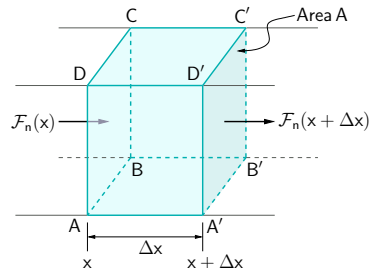
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$$(A \Delta x) \frac{\partial n}{\partial t} = \mathcal{F}_n(x) A - \mathcal{F}_n(x + \Delta x) A - (R - G) A \Delta x$$



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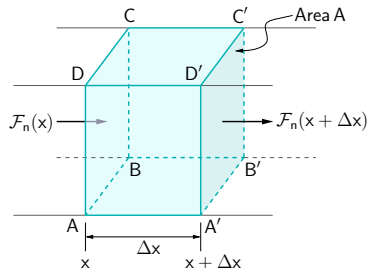
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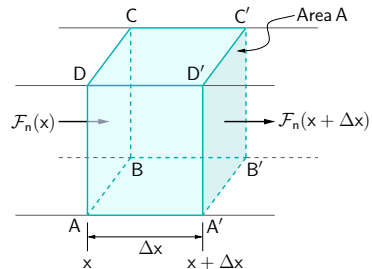
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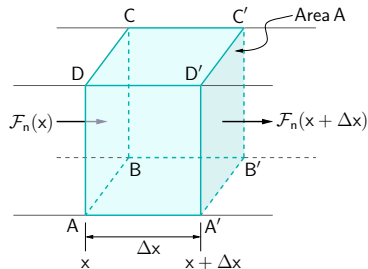
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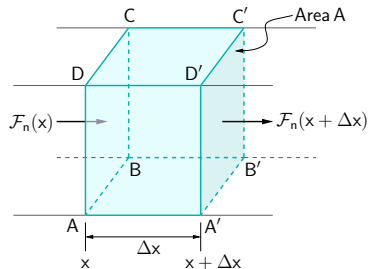
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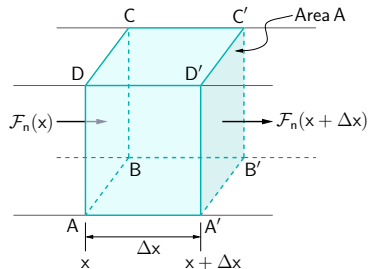
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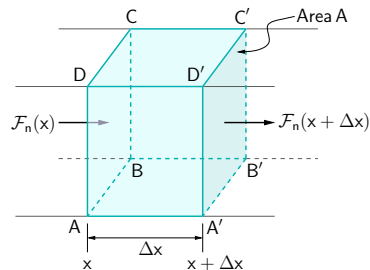
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We can rewrite the continuity equations in terms of the current densities

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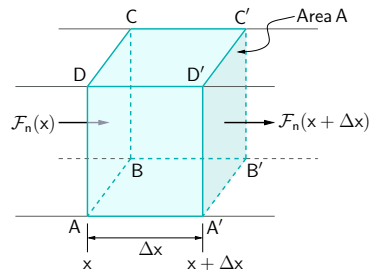
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How does a semiconductor device simulator work?

A semiconductor device simulator solves the following coupled differential equations in a self-consistent manner:

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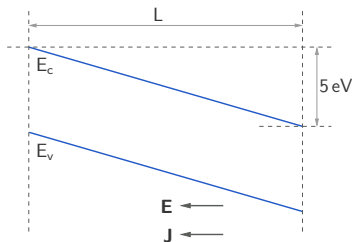
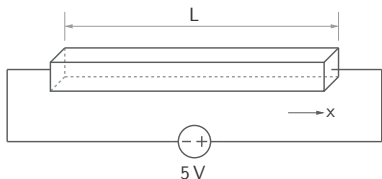
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The general problem is very complex and needs to be solved numerically.

However, we can gain significant insight by considering examples which represent situations in real semiconductor devices.

Silicon bar example (revisited): consistency check



$$L = 50 \mu\text{m}$$

$$N_d = 5 \times 10^{17} \text{ cm}^{-3}$$

$$T = 300 \text{ K } (n_i = 10^{10} \text{ cm}^{-3})$$

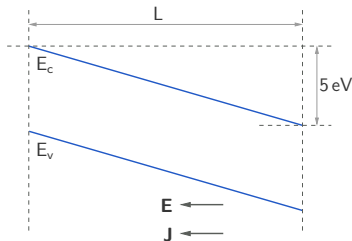
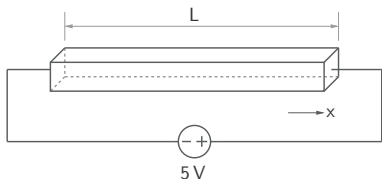
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(b) $n \approx N_d = 5 \times 10^{17} \text{ cm}^{-3}$ for $0 < x < L$.

(c) $\mathcal{E} = 1 \text{ kV/cm}$, $J \approx J_n^{\text{drift}} = 3.2 \times 10^4 \text{ A/cm}^2$ ($J_p^{\text{drift}} \approx 0$, assuming p to be negligibly small).

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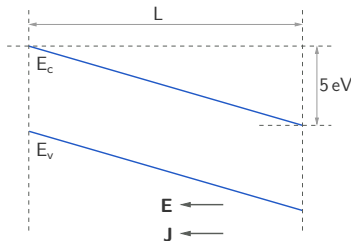
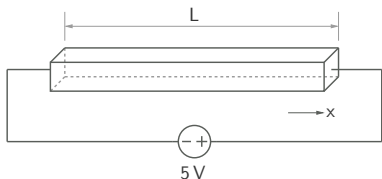
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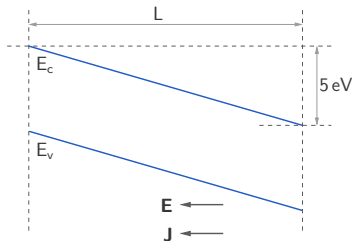
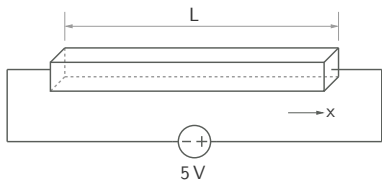
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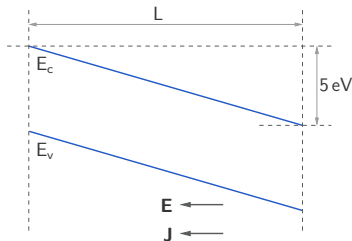
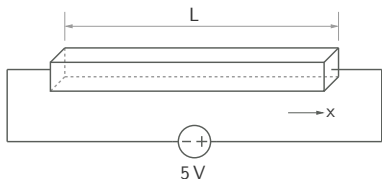
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Silicon bar example (revisited): consistency check



$$L = 50 \mu\text{m}$$

$$N_d = 5 \times 10^{17} \text{ cm}^{-3}$$

$$T = 300 \text{ K } (n_i = 10^{10} \text{ cm}^{-3})$$

Solution:

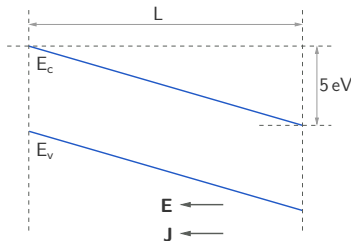
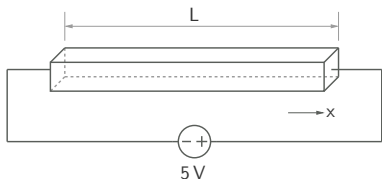
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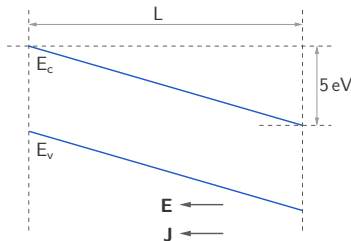
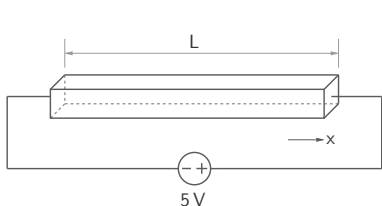
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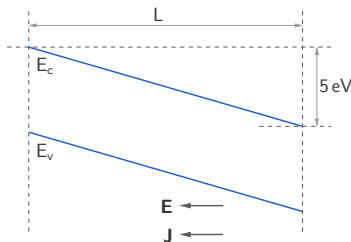
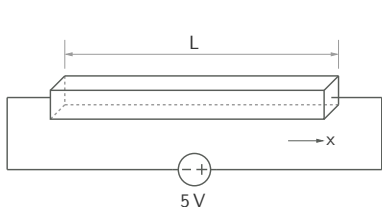
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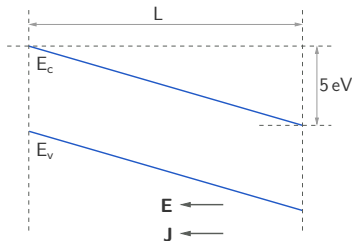
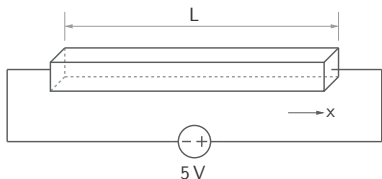
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We see that p is indeed negligibly small.

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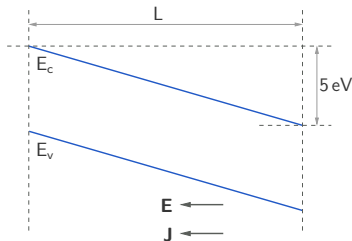
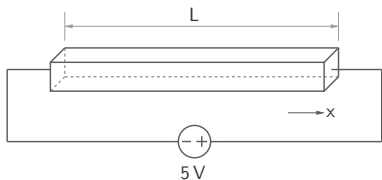
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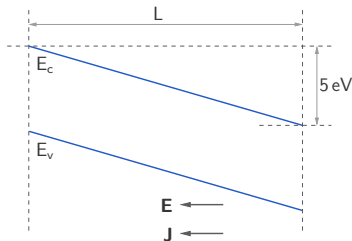
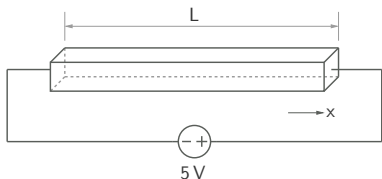
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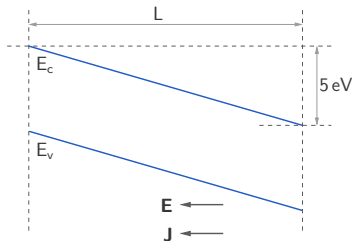
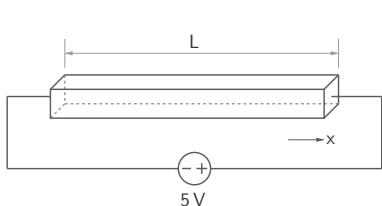
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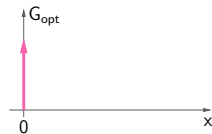
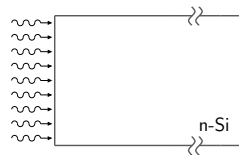
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$$\frac{J_p}{J_n} \approx \frac{J_p^{\text{drift}}}{J_n^{\text{drift}}} = \frac{\mu_p}{\mu_n} \frac{p_0}{n_0} = \frac{\mu_p}{\mu_n} \frac{n_i^2}{n_0^2} = \frac{\mu_p}{\mu_n} \left(\frac{10^{10}}{5 \times 10^{17}} \right)^2 = \frac{\mu_p}{\mu_n} \times 4 \times 10^{-16}, \text{ really small!}$$

Example

Consider an n -type silicon sample with $N_d = 10^{17} \text{ cm}^{-3}$. Light is (continuously) incident on its surface, resulting in an optical generation rate shown in the figure.

(We are assuming here that the light is entirely absorbed in a very thin region near the semiconductor surface ($x = 0$) and does not penetrate deeper.)

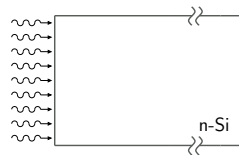


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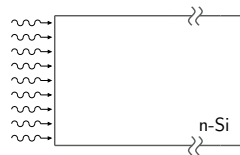
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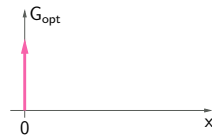
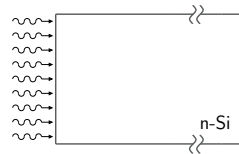
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Solve the continuity equation for holes and obtain $\Delta p(x)$. ($T = 300 \text{ K}$)



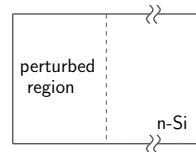
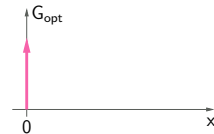
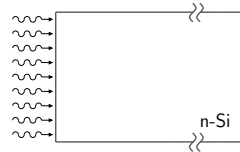
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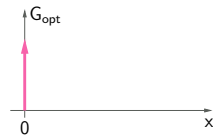
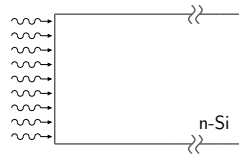
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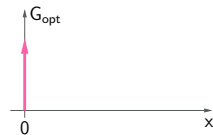
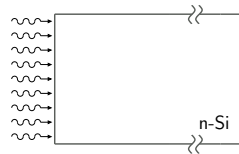
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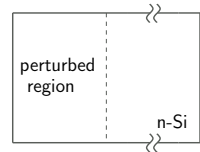
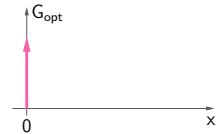
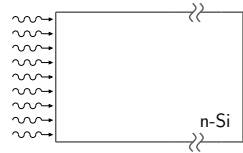


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- * We assume steady-state situation in which all quantities have settled to their steady-state forms, not varying with time.

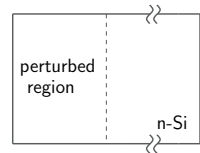
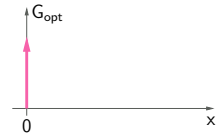
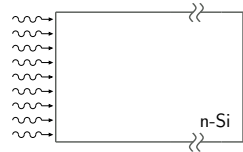


* Continuity equation for holes: $\frac{\partial p}{\partial t} = -\frac{\partial \mathcal{F}_p}{\partial x} - (R - G) = 0.$



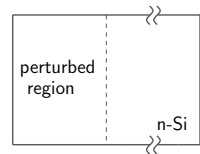
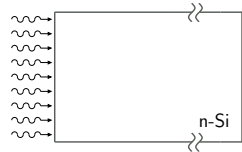
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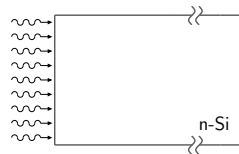
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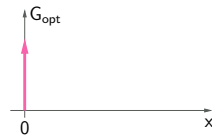
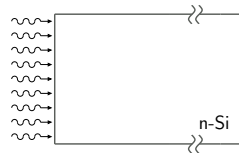
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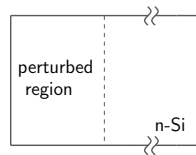
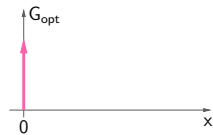
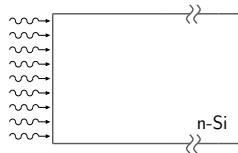


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- * Let us assume that $J_p^{\text{drift}} \ll J_p^{\text{diff}}$ (to be verified later)

$$\rightarrow \mathcal{F}_p \approx \mathcal{F}_p^{\text{diff}} = -D_p \frac{\partial p}{\partial x} = -D_p \frac{\partial (p_0 + \Delta p)}{\partial x} = -D_p \frac{\partial \Delta p}{\partial x}.$$

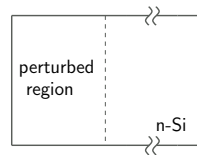
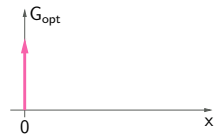
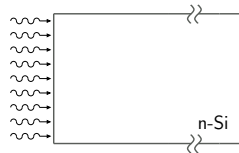


$$-\frac{\partial \mathcal{F}_p}{\partial x} - (R - G) = 0 \rightarrow -\frac{\partial}{\partial x} \left(-D_p \frac{\partial \Delta p}{\partial x} \right) - \frac{\Delta p}{\tau_p} = 0.$$



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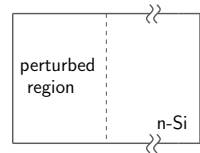
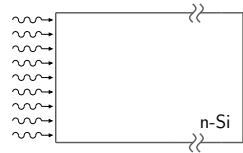
$$\rightarrow \frac{\partial^2 \Delta p}{\partial x^2} - \frac{\Delta p}{D_p \tau_p} = 0.$$



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The quantity $\sqrt{D_p \tau_p}$ has units of $\sqrt{\frac{\text{cm}^2}{\text{s}}} \times \text{s} = \text{cm}$ and is called the “hole diffusion length” L_p — also, in this case, the “minority carrier diffusion length” since holes are the minority carriers.



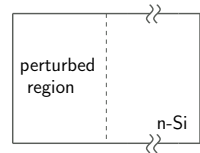
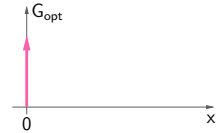
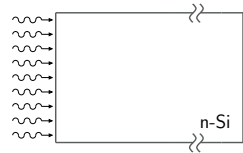
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With this definition, we have

$$\frac{\partial^2 \Delta p}{\partial x^2} = \frac{\Delta p}{L_p^2} \rightarrow \Delta p(x) = A e^{-x/L_p} + B e^{x/L_p}.$$



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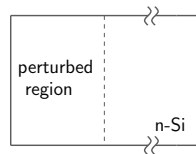
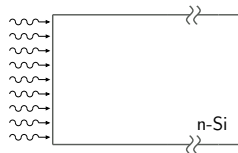
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Using the boundary conditions, i.e., $\Delta p(0) = \Delta p_1$, $\Delta p(\infty) = 0$, we get

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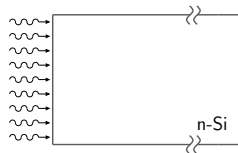
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Note:

* Our solution is valid provided J_p^{drift} is small compared to J_p^{diff} .



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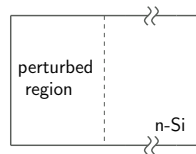
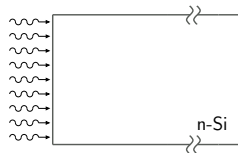
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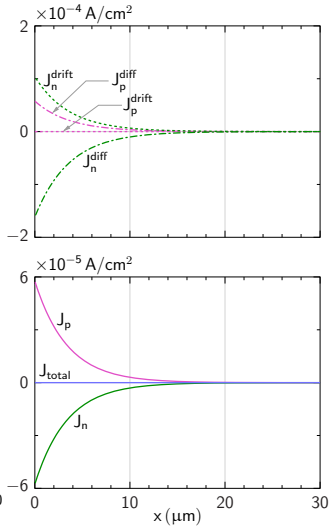
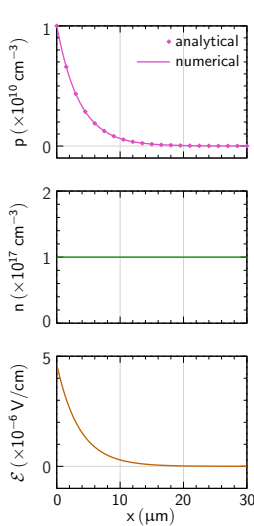
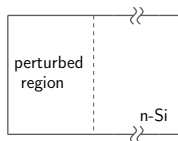
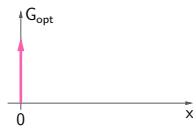
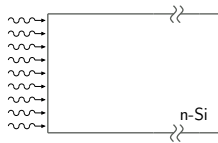
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$$\Delta p(x) = \Delta p_1 e^{-x/L_p}$$

Note:

- * Our solution is valid provided J_p^{drift} is small compared to J_p^{diff} .
- * We could not have solved the continuity equations for electrons as easily since J_n^{drift} cannot be ignored; even a small electric field causes a significant J_n^{drift} because n is large.





$$N_d = 10^{17} \text{ cm}^{-3}$$

$$\mu_n = 1400 \text{ cm}^2/\text{V-s}$$

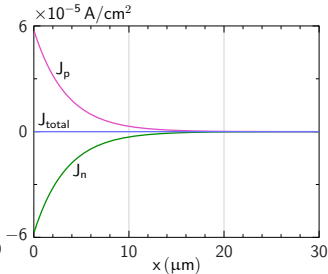
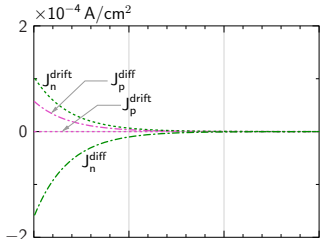
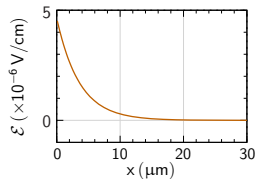
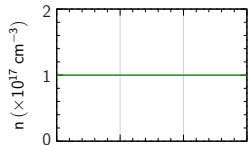
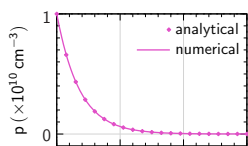
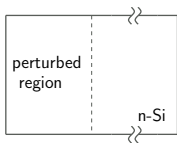
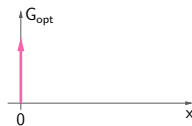
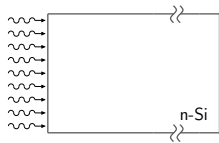
$$\mu_p = 500 \text{ cm}^2/\text{V-s}$$

$$\tau_n = 10 \text{ ns}$$

$$\tau_p = 10 \text{ ns}$$

$$E_T = E_i$$

$$T = 300 \text{ K}$$



$$N_d = 10^{17} \text{ cm}^{-3}$$

$$\mu_n = 1400 \text{ cm}^2/\text{V-s}$$

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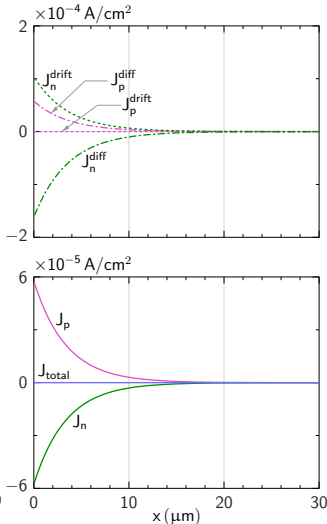
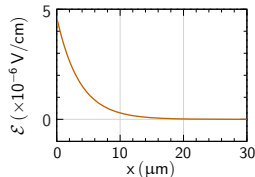
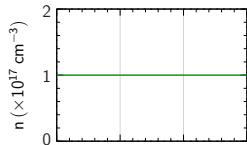
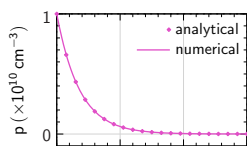
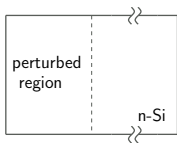
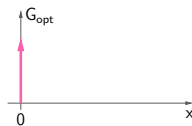
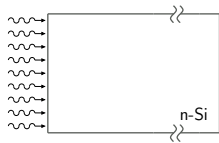
$$\tau_n = 10 \text{ ns}$$

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* The analytical solution $\Delta p = \Delta p_1 e^{-x/L_p}$ matches very well with the numerical solution.



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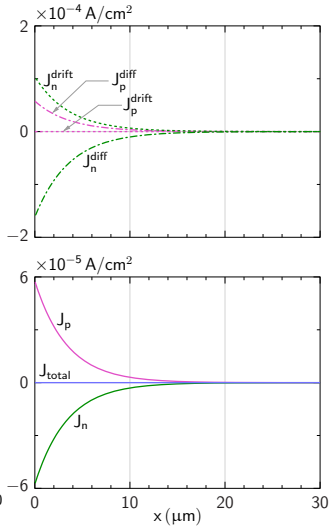
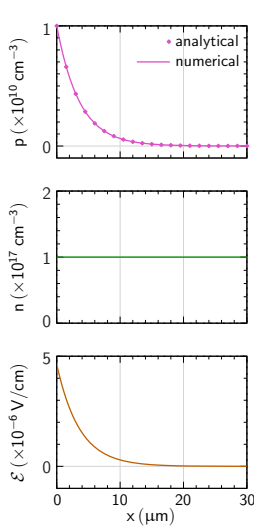
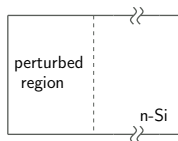
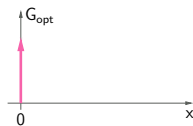
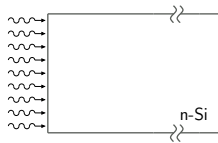
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- * The analytical solution $\Delta p = \Delta p_1 e^{-x/L_p}$ matches very well with the numerical solution.
- * J_p^{drift} is negligibly small, as we had assumed.



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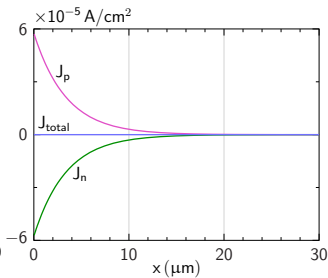
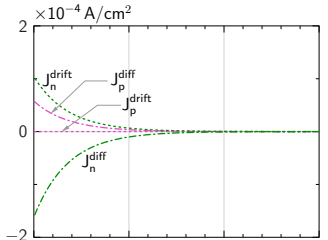
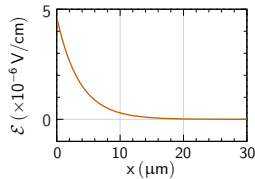
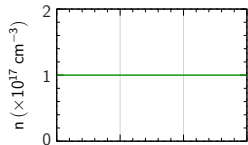
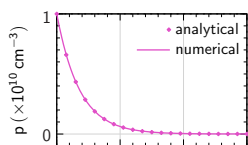
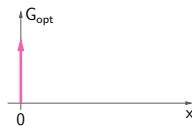
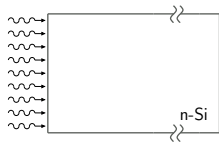
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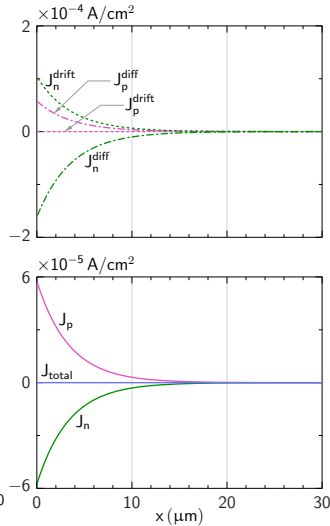
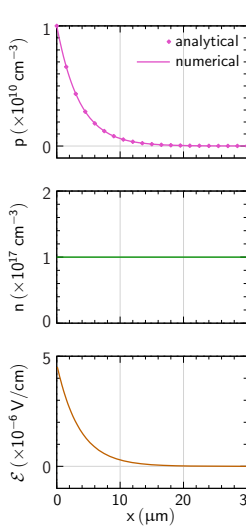
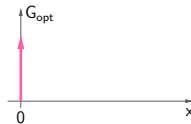
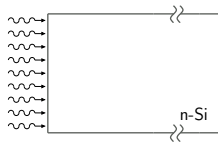
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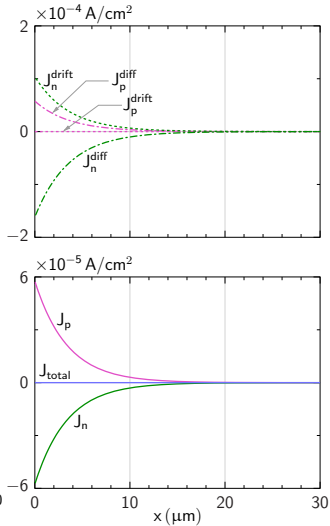
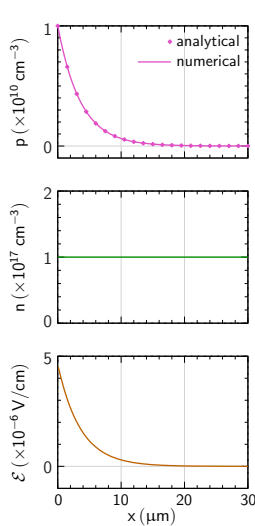
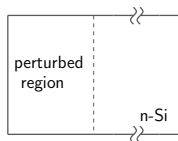
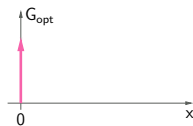
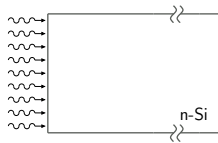
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We expect the length of the perturbed region to be about $5 L_p$ or $18 \mu\text{m}$.



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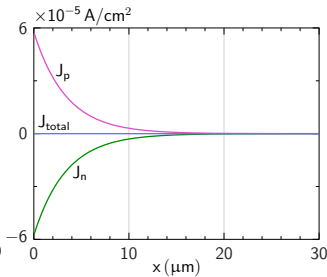
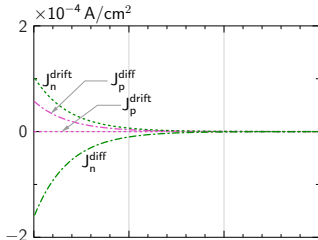
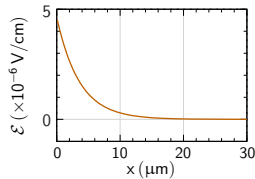
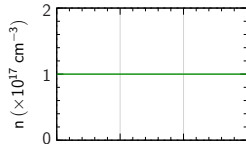
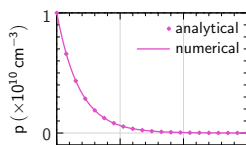
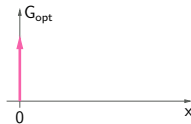
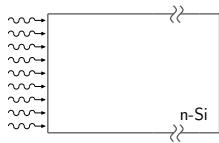
$$\mu_p = 500 \text{ cm}^2/\text{V-s}$$

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$$E_T = E_i$$

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$$N_d = 10^{17} \text{ cm}^{-3}$$

$$\mu_n = 1400 \text{ cm}^2/\text{V-s}$$

$$\mu_p = 500 \text{ cm}^2/\text{V-s}$$

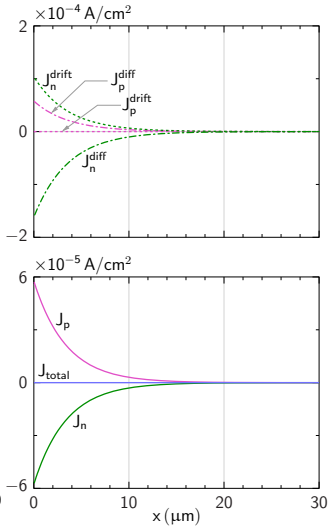
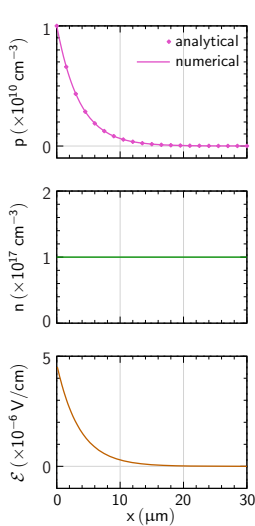
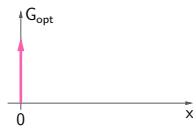
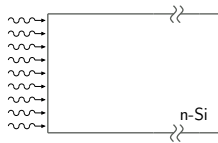
$$\tau_n = 10 \text{ ns}$$

$$\tau_p = 10 \text{ ns}$$

$$E_T = E_i$$

$$T = 300 \text{ K}$$

- * The condition $\Delta p \ll n$ (in general, the excess minority carrier concentration being much smaller than the majority carrier concentration) is called “low-level injection,” i.e., injection of a small number of minority carriers in a sea of majority carriers.



$$N_d = 10^{17} \text{ cm}^{-3}$$

$$\mu_n = 1400 \text{ cm}^2/\text{V-s}$$

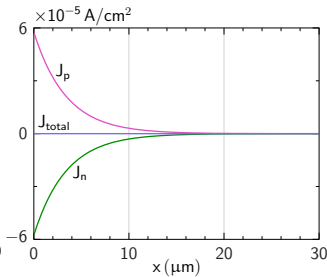
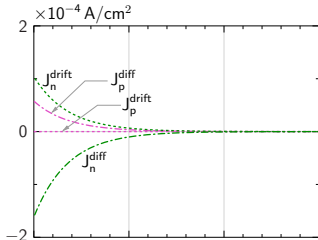
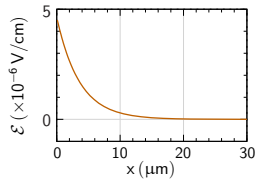
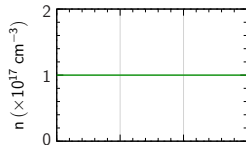
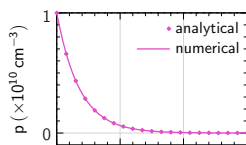
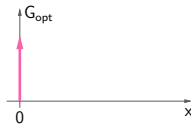
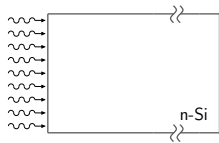
$$\mu_p = 500 \text{ cm}^2/\text{V-s}$$

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$$\tau_p = 10 \text{ ns}$$

$$E_T = E_i$$

$$T = 300 \text{ K}$$



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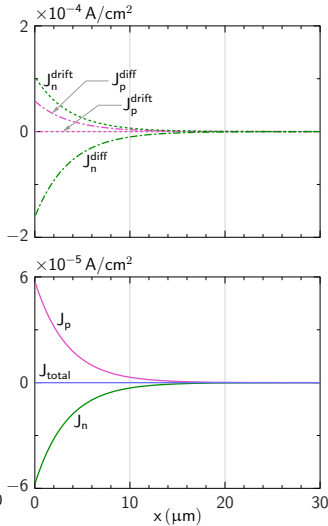
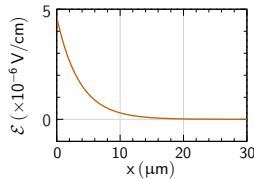
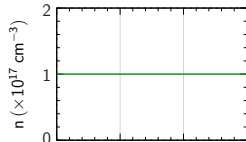
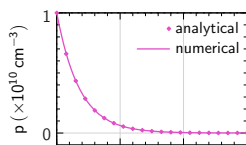
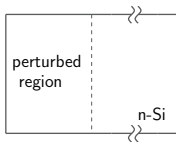
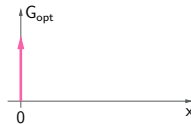
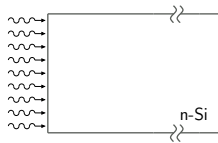
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$$E_T = E_i$$

$$T = 300 \text{ K}$$

- * The electron density is essentially constant ($= n_0$), but there is a small change in n with respect to x which gives rise to a non-zero J_n^{diff} . $\Delta n(x) \approx \Delta p(x)$ (not shown).



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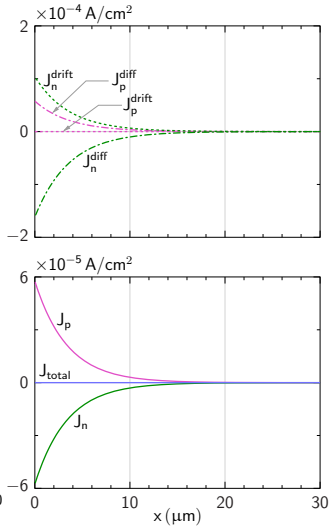
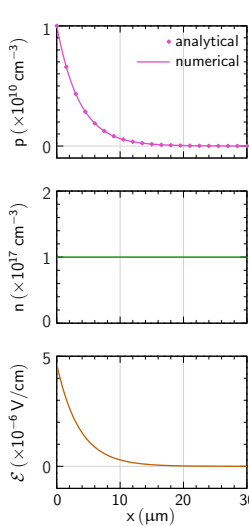
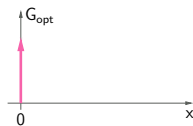
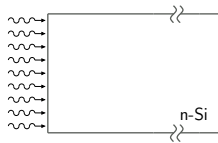
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- * The electric field is very small, but it is sufficient to cause a significant J_n^{drift} because n is large.



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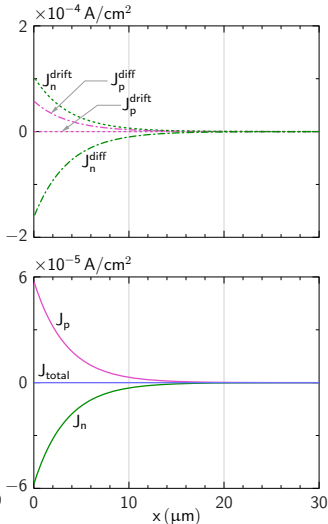
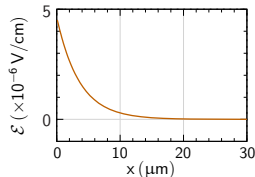
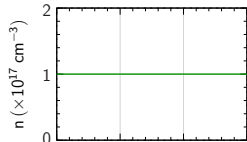
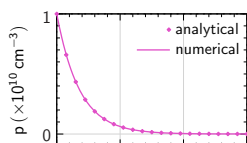
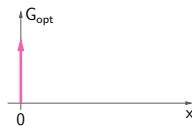
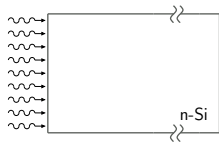
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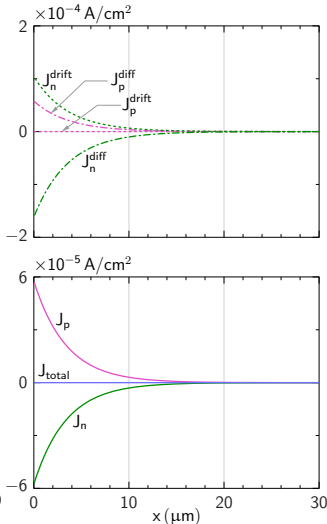
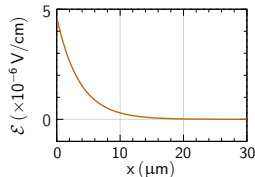
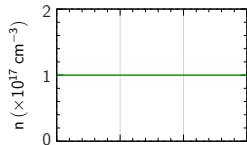
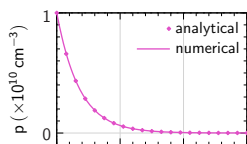
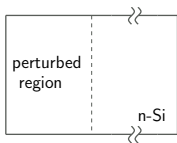
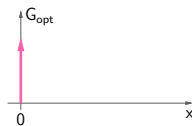
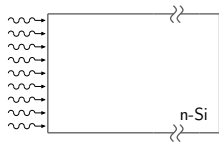
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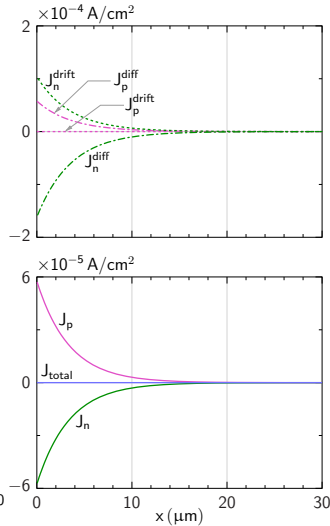
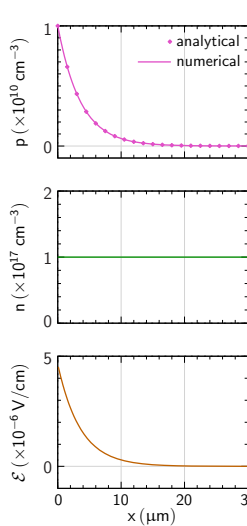
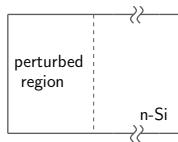
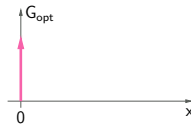
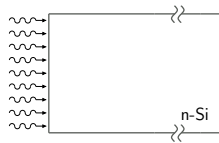
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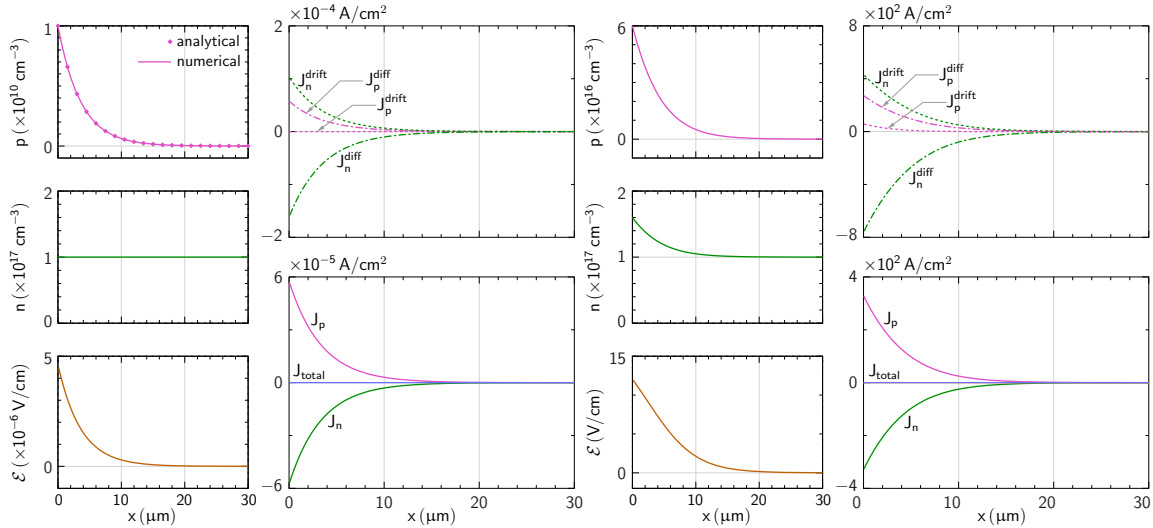
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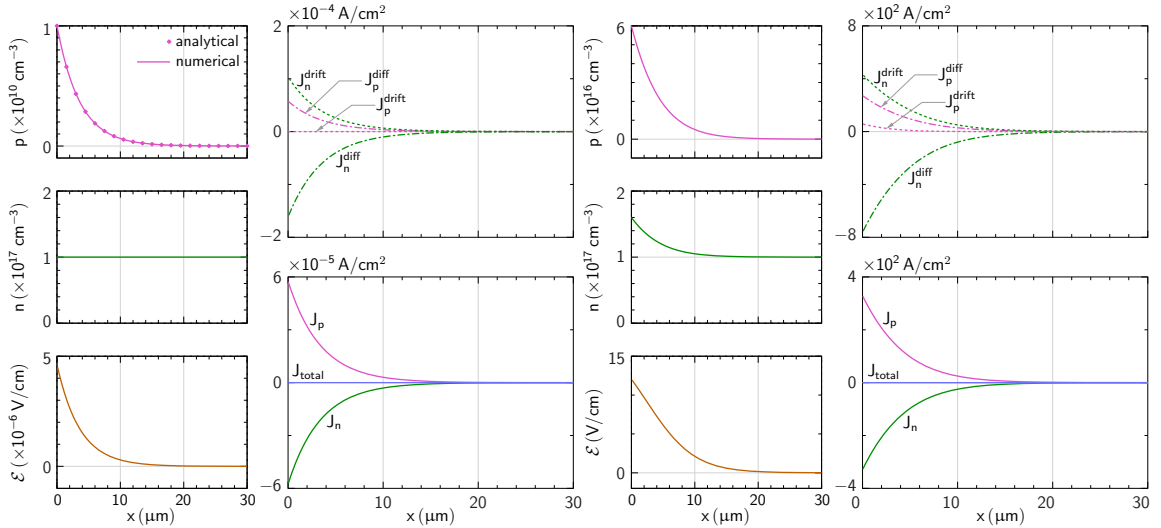
$$\tau_p = 10 \text{ ns}$$

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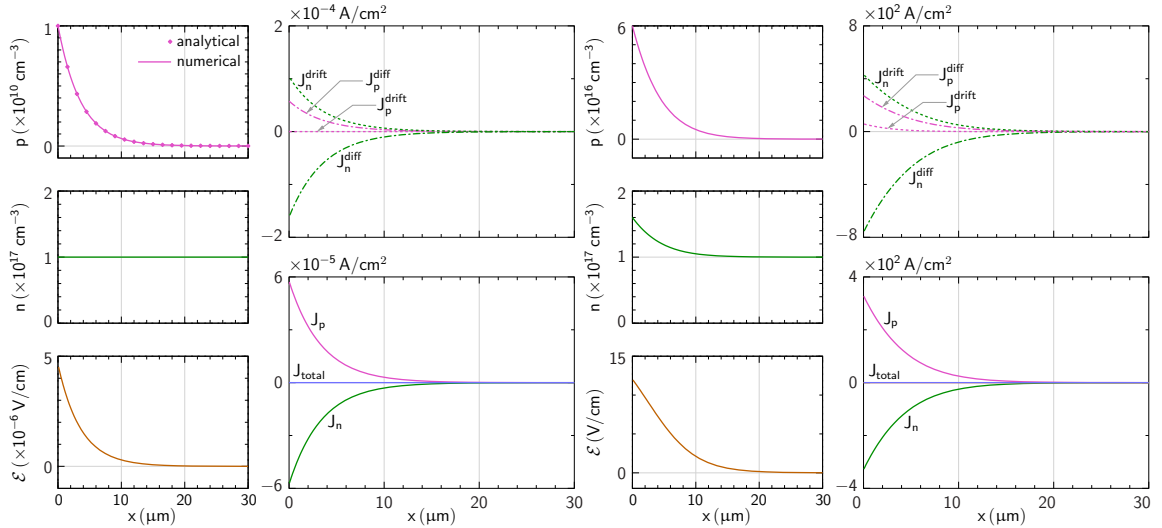
$$T = 300 \text{ K}$$

- * The total current $J = J_n + J_p$ is zero throughout since we have an open-circuit condition.
- * The voltage drop ($\int \mathcal{E} dx$ in magnitude) is very small.
- * To summarise, $\Delta p \ll n_0$, $J_p \approx J_p^{\text{diff}}$, $\Delta n(x) \approx \Delta p(x) \rightarrow$ charge neutrality \rightarrow small \mathcal{E} , and $J^{\text{total}} = 0$.

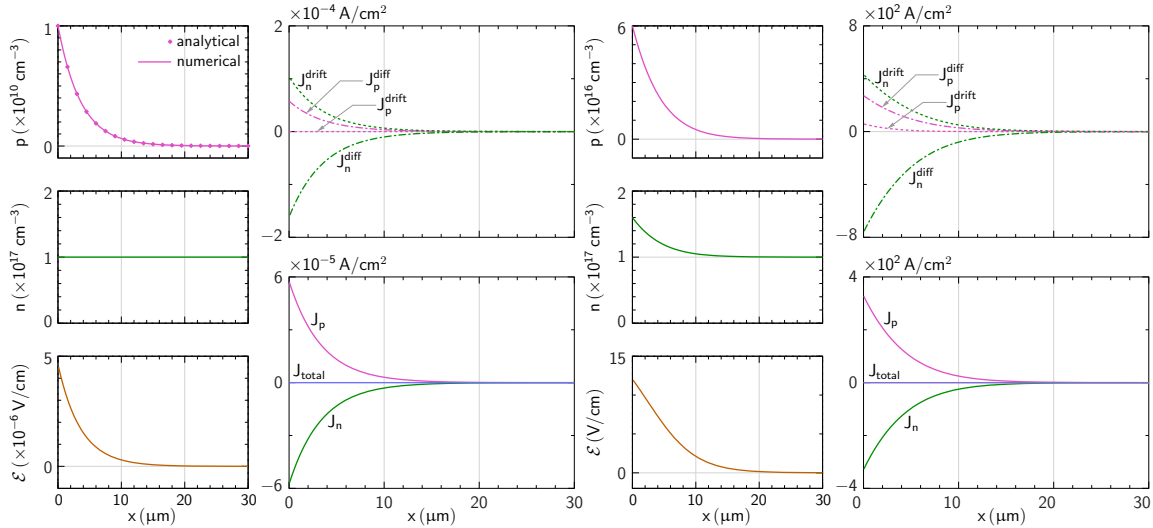


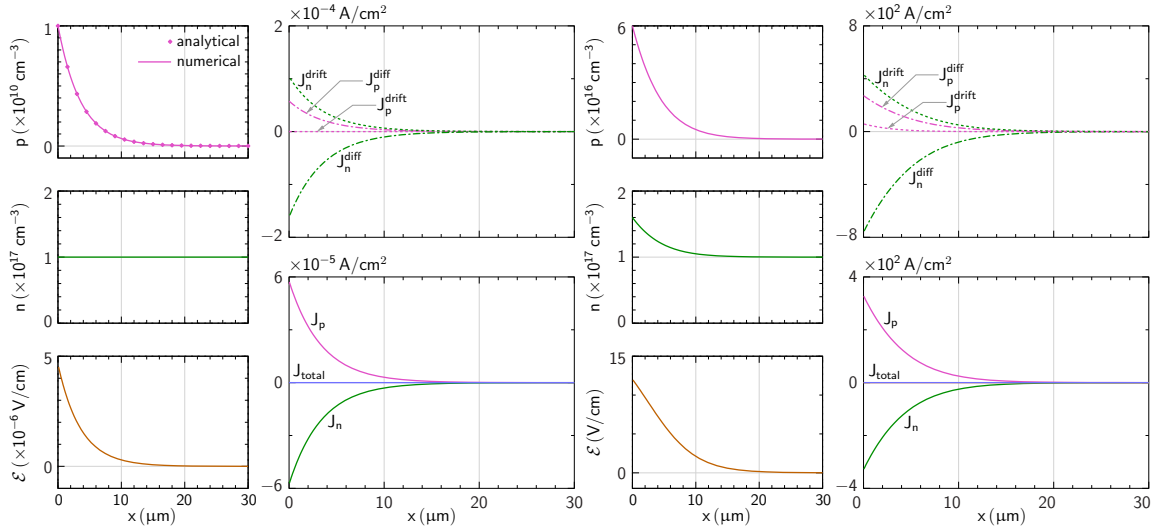


* Suppose G_{opt} is increased such that $\Delta p_1 = 6 \times 10^{16} \text{ cm}^{-3}$. $\Delta p(0)$ is now comparable to the majority carrier density, and we have a high-level injection situation.

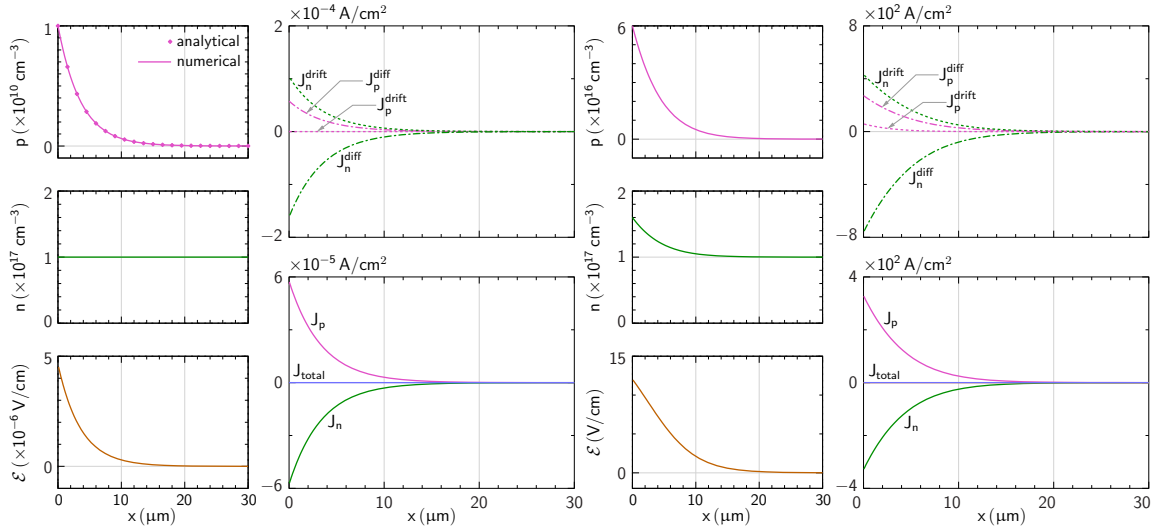


- * Suppose G_{opt} is increased such that $\Delta p_1 = 6 \times 10^{16} \text{ cm}^{-3}$. $\Delta p(0)$ is now comparable to the majority carrier density, and we have a high-level injection situation.
- * J_p^{drift} is comparable to J_p^{diff} with high-level injection \rightarrow We would not be able to solve the continuity equation for holes analytically.





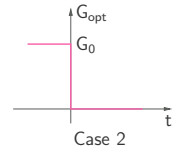
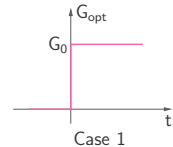
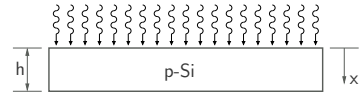
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- * $J^{\text{total}} = J_n + J_p$ remains equal to zero even with high-level injection.

Example

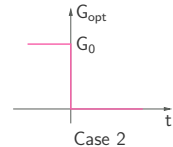
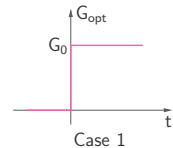
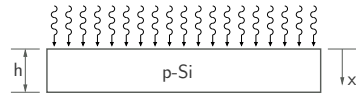
Consider a p -type silicon sample with $N_a = 5 \times 10^{17} \text{ cm}^{-3}$ at $T = 300 \text{ K}$. When it is illuminated uniformly with light of a certain wavelength, there is uniform generation throughout the sample at the rate of $G_0 / \text{cm}^3\text{-s}$, where G_0 depends on the intensity of the incident light.



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For the excitations shown as Case 1 and Case 2, how does the excess electron concentration $\Delta n = n - n_0$ vary with time?

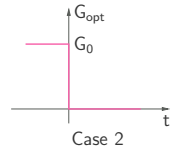
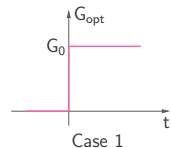
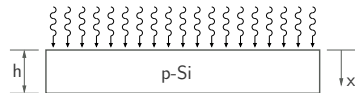


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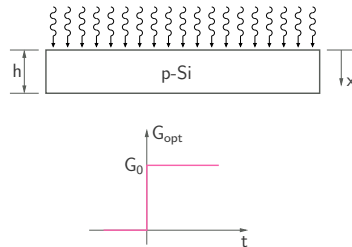
Note: The condition of uniform generation holds if the thickness of the sample h is much smaller than $1/\alpha$, where α is the absorption coefficient of silicon at the wavelength of the incident light.



Example: Case 1

Continuity equation for the minority carriers (electrons) for $t > 0$ is,

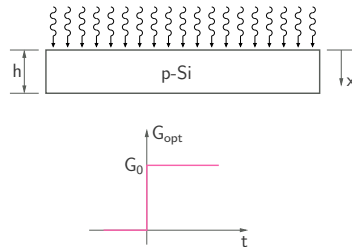
$$\frac{\partial n}{\partial t} = -\frac{\partial \mathcal{F}_n}{\partial x} - (R - G)_{\text{SRH}} + G_{\text{opt}}$$



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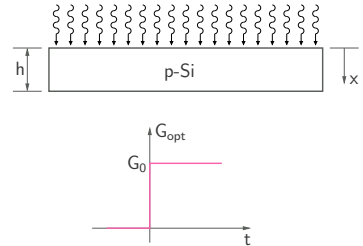
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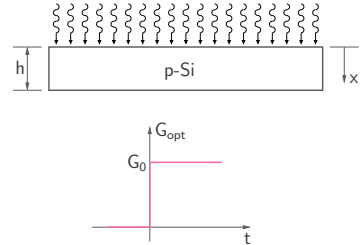
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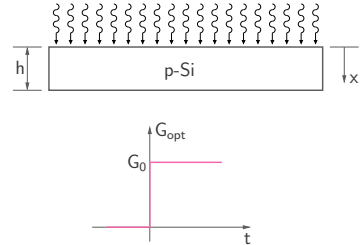
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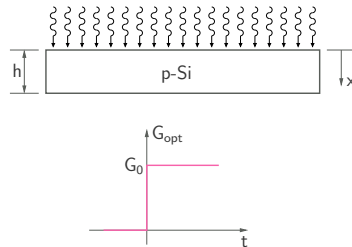
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Homogeneous solution: $\Delta n^{(h)} = A e^{-t/\tau_n}$.



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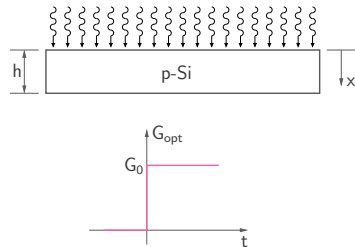
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Homogeneous solution: $\Delta n^{(h)} = A e^{-t/\tau_n}$.

Particular solution: $\Delta n^{(p)} = G_0 \tau_n$.



Example: Case 1

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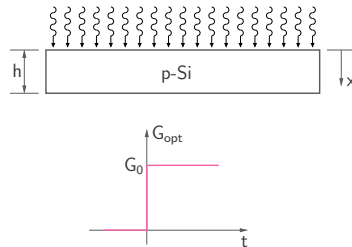
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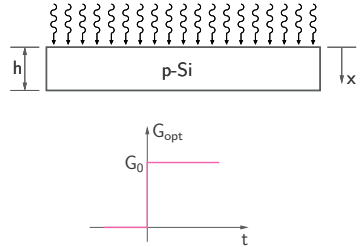
$$\rightarrow \Delta n(t) = A e^{-t/\tau_n} + G_0 \tau_n, \quad t > 0.$$



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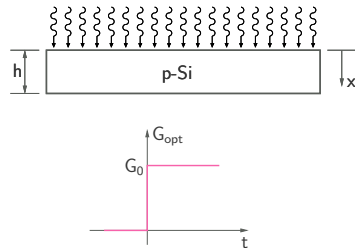


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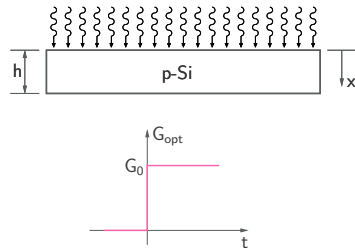
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Using $\Delta n(0^+) = 0$, we get $A = -G_0 \tau_n$, and

$$\Delta n(t) = G_0 \tau_n (1 - e^{-t/\tau_n})$$



Example: Case 1

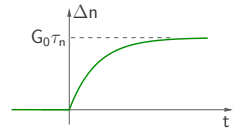
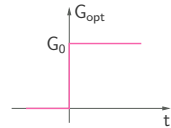
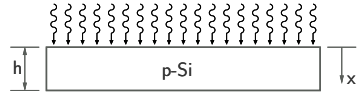
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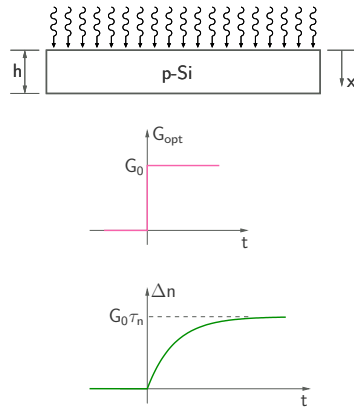
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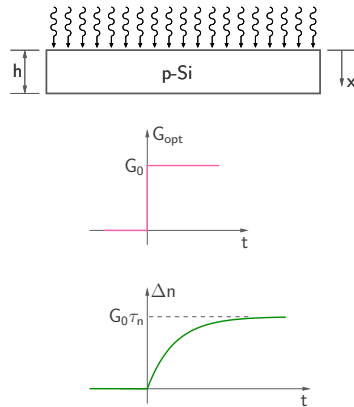
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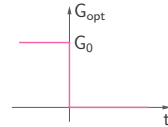
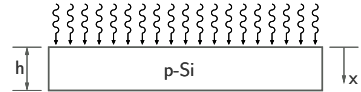
$$\rightarrow G_0 = \frac{\Delta n}{\tau_n} \rightarrow \Delta n = G_0 \tau_n, \text{ as predicted by the above equation.}$$



Example: Case 2

Continuity equation for the minority carriers (electrons) for $t > 0$ is,

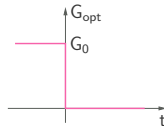
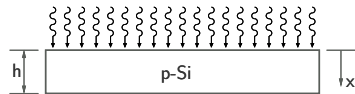
$$\frac{\partial n}{\partial t} = -\frac{\partial \mathcal{F}_n}{\partial x} - (R - G)_{\text{SRH}} \quad (\text{Note: no } G_{\text{opt}} \text{ term here})$$



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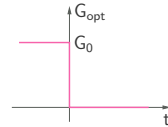
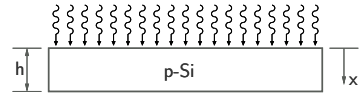
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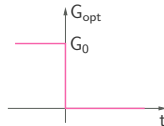
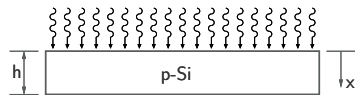
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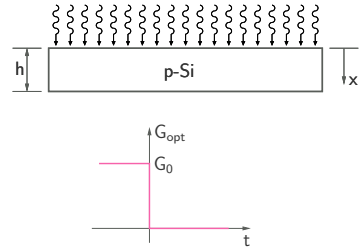
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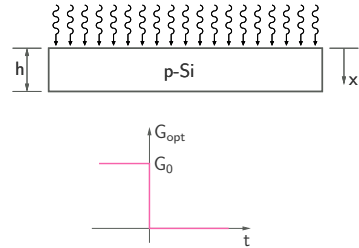
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